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OAI WINS ORDER FOR NANO IMPRINT FROM WASHINGTON STATE UNIVERSITY

May 20, 2008, San Jose, CA: OAI, a supplier of UV exposure equipment for semiconductor, MEM's, microfluidics, and nano technology, says that it has shipped its nano imprint module to Washington State University. HP Labs developed the nano imprint technology and the module can be added to any OAI mask aligner.

Washington State University purchased the nano imprint module for both R & D and teaching. The nano imprint module will be integrated with OAI's tabletop Model 200 mask aligner.

"We are pleased to work with Washington State University to help them include nano technology in their research and teaching," said Dr. Charles Turk, President of OAI. "The use of the imprint module with the Model 200 mask aligner provides a flexible platform for advanced semiconductor lithography as well as nano imprinting. The change over from lithography to nano imprinting can be accomplished in less than 15 minutes," he added. The system is scheduled for installation this summer.

OAI is a leading manufacturer of precision equipment used in the semiconductor, MEMS, and compound semiconductor industries for 30 years. Located in Silicon Valley, OAI can be contacted via e. mail: *sales @oainet.com*, Phone: *408-232-0600*, or fax: *408-433-9904*